CHAPTER III

LITERATURE REVIEWS

A.M. Kuritzkes [27] suggested that the quaternary ammonium cation-modified montmorillonite clays perform as flatting agents for lacquer systems, generally reducing gloss and specular reflection without markedly altering the transparency of such films. The quaternary ammonium cation-modified montmorillonite clay suspending agents are desirably added to nail enamel lacquers in amounts sufficient to provide concentrations varying from about 0.4 to 6% by weight of the lacquer. The commercially available used organoclays are Bentone38, Bentone27, and Bentone34 compared with others anti-setting additive. Each of organoclays was dispersed in toluene with a high shear mixer then slowing adding ethyl and amyl acetates with stirring, followed by arylsulfonamide formaldehyde resin and the plasticizer. The ethyl alcohol, which assists in the swelling of the montmorillonite, was added when the solids had dissolved and then the cellulose nitrate solution was added. Finally, titanium dioxide coated mica was mixed with above solution to be color nail enamel. After the samples had been permitted to settle for a month, some of coated mica flakes in the Bentone38 lacquer had settled, but were immediately dispersed on inverting the bottle. The modified montmorillonites showed more excellent of setting resistance, luster, and color stability than Lecithin, Magnesium stearate, and dibutylamine pyrophosphate.

T. Ikeda, and, T. Kobayashi [28] showed that the interlaminar distance (001 face) of dimethylbenzyldodecyl ammonium montmorillonite is measured by means of an X-ray diffraction device (RIGAKU Rota Slex Type RU-3) that interlaminar distance of powder is 9.4 °A and that D.B.P. (i.e. dibutyl phthalate) cannot expand the interlaminar distance of the organically modified montmorillonite clay. The good solvents which can be used as swelling substance of Bentone27 must give an expanded interlaminar distance of bentone27 not less than about 16 °A after swelling. Secondary film forming of lacquer is various molecular weight of polyethylene glycol

from 200-4000. This invention used about 5 wt% Bentone27 in total weight of nail enamel by using milling roll, a Bunbury mixer, at a temperature of about 40 through 70 °C. The viscosity of Bentone27 resulted nail enamel was 1,510 centipoise after 3 month the viscosity increased to 2,000 centipoise, also evaluated thixotropic index as 4.2. Gloss of film was about 81.7 G.U and film hardness was 110 vicker.

D.A. Pappas, and H.J. Laresen [29] disclosed the invention relates to novel, quick drying nail enamel compositions which dry in a period of time no greater than three minutes. It has been found advantage to include acetone in amounts ranging from about 4.5 to about 35wt%. Acceptable static viscosities range are from about 400 to about 1200 centipoises and may accommodate numerous pigments to produce nail enamel compositions exhibiting favorable characteristics, including acceptable durability and gloss. Gelled mixture is manufactured by adding stearalkonium hectorite into the mixture which has toluene as good solvent of stearalkonium hectorite with strong shearing force of a Hoffmeyer industrial mixer generally for a period of about at least one hour. The preferable content of stearakonium hectorite is about 3wt% of total ingredients. In the final step, one or more pigments are added to the aforementioned gelled mixture under high shear speed to produce color nail enamel. Drying time on lineta cards (3 mm draw down) at an ambient temperature of 64° F (17.8 °C) and a relative humidity of about 37% was 3 minutes and 21 seconds. Drying time in a relative humidity of about 65-70% is about 5 minutes. This formula exhibit an acceptable gloss ranging from 70 to about 95 G.U

G. G. Graves, and T. C. Jacks [30] invented nail lacquer which is made faster drying by incorporating a particular class of vinyl-silicone copolymers in range of 0.1-5 wt%. Trapping of bubbles in the dried film is avoided by incorporating a dimethicone anti-foaming agent in range of 0.02-0.3 wt%. Dimethicone included polydimethylsiloxane have viscosity about 200-500 centistokes. Stearakonium hectorite and stearakonium bentonite were preferred thixotropic agent which used composition is in amounts ranging from about 2-5 wt%. Suitably quickly drying time is considered to be 1-4 minutes. M. Sakine, M. Tamazawa, and T. Sunamori [31] disclosed a method for producing an aqueous nail enamel composition comprising the following procedure: an aqueous mixture which comprises, as essential components, water and a pigment of 3 μ m or less in average particle size at a concentration of the pigment of 60% or less and is previously subjected to contact treatment with a substance having an ion exchangeability is kneaded under heating with a polyester polymer having a chemical structure containing a phenyl group and having a weight-average molecular weight of 2000-20000 and a softening point of 120° C. There provided an aqueous nail enamel compositions, casted on a nail and dried under the conditions of 25° C and 60% relative humidity after lapse of 4 hours, the resulted nail enamel exhibited good of gloss, and color reproducibility. Drying time of coating film was less than 3 minutes and pencil hardness was HB level. No squares peeling off of 10x10 squares crosscut film by an adhesive cellophane tape. The coating film was removed by a usual remover, and degree of stain of the nail caused by the dissolved pigment was visually examined and showed that no stain occurred.

R. L. Socci, and A. Ismailer [32] have been discovered that nail enamel compositions containing cellulose nitrate, primary film forming, have a molecular weight greater than 56,000. Cellulose nitrate has many grades such as nitrocellulose RS1/2 sec. having a molecular weight of 56,000, nitrocellulose RS5-6 sec. having a molecular weight of 112,000, nitrocellulose RS15 sec. having a molecular weight of 130,000, nitrocellulose RS60-80 sec. having a molecular weight of 175,000, nitrocellulose RS150 sec. having a molecular weight of 190,000. Glossy appearance improvement can be observed by adding 2.4wt% dry bismuth oxychloride pigments producing a frosted effect. Resulted film was measured gloss at 60 °angle providing rang of 81-118 G.U.

Table 3.1 Disclosed nail enamel ingredients in US patent from 1997-2004.	
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Table 3.1 Disclosed nail enamel ingredients i	n US
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Table 3.1 Disclosed nail	enamel
Table 3.1 Disclosed	nail
Table 3.1	Disclosed
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		Information	ation				Primar	Primary Film Forming	I Forn	ning			Co-	Co-Solvent	
SN	Company	US Pat No	Year	Compos	Example	CN	CN	CN	CN	CN	CN	IPA	Ethyl	Butyl	Diacetone
			ģ	1						15-	30-				
				28			1/2	1/4	5-6	20	40		Alcohol	Alcohol	Alcohol
1	Kirker	7640314B2	2004	1	1	7.3			T	ı	1	6.3	6		0.7
7	Tevco	6537530B2	2003	2	4	14.71	•	•	1	1	1	1		1	1
3	Loreal	6555096B2	2003	212	4	14	•	•	•	1		1.03	1	6	4.5
4	Loreal	6555096B2	2003	2	4	14	1	•	•	1		1.03		9	4.5
5	Engelhard	6626989B1	2003		1 1	1	,			2.9	6.6	5.1	•	1	
9	Shiseido	6656486B2	2003	1	25	20								1	1
7	ProStrong	6627181B1	2003	- I %	3		15	- 1			•	6.5			1
~	Loreal	6555096B2	2003	3	4	14	1	,	1	1	1	1.03	-	6	4.5
6	Loreal	6555096B2	2003	4	4	14	1			1	8	1.03		6	4.5
10	Kirker	6352687B1	2002	0 1	3	1		15.2			1	8.08		1	1
11	Revlon	6485731B1	2002	3	9	1	•	13.3	•		1	7	- / /	1	•
12	Loreal	6156325	2000	1	3	10					1	5	-	1	
13	Loreal	6156325	2000	2	3	14.7	•	1			•	5		-	1
14	Loreal	6156325	2000	3	3	10			1	1	1	5	1	1	1
15	Maybeline	5972095	1999	1		18	•	•	•		1	5		1	1
16	Kirker	5977217	1999	4	4	11.5	1			•	1	6.4	1		0.5
17	Kirker	5863523	1999		5	I	,	3.8	4.2	,	I.	14.56	•	•	1
18	Maybeline	5766332	1998	21	1	18	1	1	1	ı	I	5	1	1	1
19	Almell	5662891	1997	1	4	16.4	•	1	1	ı	I	2.34	1	3.52	I

	Heptane		I	1	ı	ı	1	1	18	ı	ı	1	1	1	•	1	1	0.5	1	1	•
	Methyl Ethyl	Ketone	1	1		1		20	1	•	1	'		•	•	•	1	•	•	ı	•
True-Solvent	Acetone		1			1		20	-							•	1	1	1	1	,
True	Propyl	Acetate	1		9.7	9.7		1	5	9.7	9.7	-12		20	15	20	1	0.5	1	•	,
	Ethyl	Acetate	38.46	23.247	24.8	22.8	•	1	15	24.4	23.8		37.9	25.65	21	23.65	30.5	41.2	30.43	30.5	34 78
	Butyl	Acetate	24.1	22.307	20.7	19.7	37.6	r	25	20.7	20.7	20.47	26.3	25	24	25	25	15.8	25.1	25	23.19
Diluent	Toluene		1	1	ı	•	-	1	•	1	1	26.6	•		•	1	1	-		1	1
	Example		1	4	4	4	1	25	3	4	4	3	9	3	3	3	1	4	5	1	4
	Compos	ລ	1	2	1	2	1	1	01	3	4	1	3	1	2	3	1	4	1		1
tion	Year	9	2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information	US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5667801
	Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	SN		1	7	e	4	S	9	2	8	6	10	11	12	13	14	15	16	17	18	10

		Citrate		1	1		1	1	8		I				ı	I	1	1	1	1		1
	Acetyl	Tributyl	citrate	1	1	2	2	1	1		2	7	1	3.5	ı	1	1			1	1	
	Glyceryl	acetyl	ricinoleate			1				-	-	•	•	-	1		1	1		1	1	1
izer		SAI		2.3	1	1	1	•	1			1	1	-	5	1	5	1	5.9	1	1	1
Plasticizer		N-ethyl	tosylamide		1	1	-	-		-		-	-	-	5	7.5	5	1	•	•	1	1
	Cam	phor		1.35	•	,	•		•	2	7 -		-			1	1	1	0.2	1	1	8
		Dimethoxy	phthalate	1	1					19- 19		-	-			1				ı	1	1
		DBP		1.6	1			1		4	1	•	6.25	1		1	1	5	1.7	1	5	I
	Exam	ple		1	4	4	4	1	25	3	4	4	3	9	3	3	3	1	4	5	1	4
	Com	sod		1	2	1	2	1	1	1	Э	4	1	3	1	2	3	1	4	1	1	1
u		Year		2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information		US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
		Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	S	Z		1	2	3	4	5	9	7	8	6	10	11	12	13	14	15	16	17	18	19

																				1	1	
		Naphthenic	material	1	1	1	1	•	1	1	8	1	ı	1	1	•	1	1	1	•	1	4.45
	Citric	Acid	Solution	0.01	0.2	1			1		1	1				•		•		1	1	1
Plasticizer (continue)	Ethylene	glycol	monoethylether	1	•	•		1	1	-	-				-	-	-	- 1		1		1
Plasticize	Butyl	Benzyl	Phthalate	-			1	-		-	-	-		-		-	-	-		•	1	3.51
		Glyceryl	Tribenzoate	1	1	1	1	-	1		1 - C	-	-	-		1	1	1	1	1	ı	1.87
		Triphenyl	phosphate	1	1	4.57	4.57	-	1	3.5	4.57	4.57					•	•	2.9	9	1	1
		Example		1	4	4	4		25	3	4	4	3	9	3	3	3	1	4	5	1	4
		Compos	2	1	2	1	2	010	1	1	3	4	1	3	1	2	3	1	4	1		1
tion		Year	ġ	2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information		US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
		Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	19 Almell
		SN			5	S	4	5	9	7	8	6	10	11	12	13	14	15	16	17	18	19

	Tosylamide		EpoxyResin	1	,	2.4	2.4		1		2.4	2.4	1	,	5	6	2	,	6.6	1	1	1
-	Polyether		modified I		•	1	1	1	1	1	1	1	1		1	1	1		0.4	1		1
orming	Alkyd Polysiloxane		Copolymer		ı	1	1	ı	ı	1	1	I	1	•	-	ı	ı	ı	1	ı	1	0.234
Secondary Film Forming	Alkyd		resin				ı	•				-	1					1		1		1
Seconda	Formaldehyde		Resin	1	1	1		1	1	1		1			-	1	1	1			1	2.58
	Toluenesulfonamide	Formaldehyde	Resin				- 33				-8- 0				-			•		12.8		4.68
	Example	i.		1	4	4	4	1	25	e	4	4	3	9	3	3	3	1	4	5	1	4
	Compos			1	2	-	2	010	1	1	3	4	1	e	0 1	2	3	1	4	1	1 0	1
tion	Year		9	2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information	US Pat No	×		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
	Company			Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	SN	Nor Harve		1	7	e	4	5	9	7	~		10	11	12	13	14	15	+	17	18	19

	Adhesion	Promoter	Resin	1	2.831				1			•	•		1	I		1	1		ı	I
Secondary Film Forming (continue)	Maleic Modified		Resin Polymer	1	ı	ı	-	-	-	-									1	ı		1.17
y Film For	Vinyl		Silicone	1	1	1	-				-	-			-	-		0.8		1	0.8	1
Secondar	Polyester	•			11.2	2.4	2.4		1	9	2.4	2.4	8.9				1	6	0.6		6	
	Acrylates	•	Copolymer	1	1	4.42	4.42		1	-0.65	4.42	4.42		-	1.5	,	1.5		0.7	1	1	
	Example	-		1	4	4	4	1	25	3	4	4	3	6	3	3	3	1	4	5	1	4
	Compos	-	9	1	2	$0 1 \Sigma$	2	1	1	1	3	4	1	3	1	2	3	1	4		0.1	1
tion	Year			2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information	US Pat No			7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
	Company	C		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	15 Maybeline	Kirker	17 Kirker	Maybeline	19 Almell
	NS	2		1	7	e	4	5	9	7	~	6	10	11	12	13	14	15	16	17	18	19

	Aerosil	200	(fumed	silica)	1	1	1	1	1	1	1	1	1	3.5	1	1	I	1	1	1	1	1	1
Thixotropic agent		Modified Urea		Urethane(BYK410)	1		0.5	0.5				0.5	0.5			0.25	0.2	0.25		1	1		1
Thixot		Stearakonium		Hectorite	1.1	14.187	1					-					1		2	0.1	1	2	I
		Bentone38			1		1	-		•	-	1	-	-		1				0.8	1.05	1	8
Anti-Foaming		Dimethicone			0.01	1					-		-	-						0.1	1		1
Anti-F	Dow	Corning		200/350		1	1	-			-	-	1		1	-			0.2	-		0.2	1
		Example			1	4	4	4	1	25	3	4	4	3	6	3	3	3	1	4	5	1	4
		Compos	2	9	1	2		2	1	1	1	3	4	1	3	1	2	Э	1	4	1	1	1
ttion		Year	9	1	2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information		US Pat No			7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
		Company			Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
		SN			1	7	m	4	S	9	7	∞	6	10	11	12	13	14	15	16	17	18	19

		h		ide																			
		Bismuth		oxychloride	2.4	T	,	1	'	1	1	•	•	'	•	1	•	•	'	'	1	'	•
	Lake	D&C	Yellow	No5	0.08	1	•				•	•		1					1	0.1			
	Red	Iron		Oxide		1					1			•				•	•	0.1	•	•	•
Pigment&Pearl	D&C Red	No7	Calcium	lake	I	1	1	1	-	-	I	-	0.1	-	T	-	1	1	1	ı	1	1	1
Pigr	D&C Red	No34	Calcium	lake	I	T	1	-	-	1	1	0.1				1	1				1		,
	D&C Red	No6	Barium	lake	1	1						0.3	-							1	ı	1	1
		Titanium		dioxide		,	4	•	1	1	1	1	-			1	I	1		2	1	I	
		Example	4		1	4	4	4	1	25	3	4	4	3	6	3	3	3	1	4	5	1	4
		Compos			1	2	1	2	1	1	1	3	4	1	3	1	2	3	1	4	1	1	1
tion		Year	2	1	2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information		US Pat No			7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
		Company	Con Jerro o		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Mavbeline	Kirker	Kirker	Maybeline	Almell
		NS	1		-	7	e	4	S	9	2	00	6	10	11	12	13	14	15	16	17	18	19

			er																				
UV resistant		NN	Absorber	1	0.149	1	1	ı	1	ı	1	1	1	1	1	ı	1	1	1	ı	ı	1	
UV re	Renzo-		phenone1	ı		1				1					0.1	0.1	0.1	0.5	0.05	1	0.5	0.023	
		Glitter		I		1	1	1	1		•	1	11			1	1		•	1	1	ı	
	Pig	ment		1	ı	1		1	1	1	1	1	1		1	1	1	ı	1	1.06	1	ı	
continue)	Black	Iron	Oxide	0.21			•	1		-	-	1	1		-		1		1.3			1	
Pigment&Pearl (continue)		Colorants/	Pearl	1	ı	I			4	1	-	1	-	-	-	2	2	3	1	1	3	ı	
Pign	Ferric	Ammonium	Ferrocyanide	0.05		I		1	-	1	2 (2) r	0.02	-		-	-				1	1	1	
		Mica		1	1	1	9	-		1	-	0.7					•		-	3	1	1	
		Example		1	4	4	4	1	25	3	4	4	3	6	3	3	3	1	4	5	1	4	
		Compos	ิล	01	2	1	2	610	1	1	3	4	0 1	3		2	3	1	4	1		1	,
tion		Year		2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997	-
Information		US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891	
		Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell	•
		SN		-	7	e	4	5	9	7	8	6	10	11	12	13	14	15	16	17	18	19	

N Company US Pat No Year Company Facupha Encodium Proteink Amino Polyethytene 1 Kirker 7640314B2 2004 1 1 -			Information	ation					Others			
Kirker 7640314B2 2004 1 1 Panthenol Lanolin methoxysilance Tevco 6537530B2 2003 1 1 - <th>SN</th> <th>Company</th> <th>US Pat No</th> <th>Year</th> <th></th> <th>Example</th> <th>Etocrylene</th> <th>Dex-</th> <th>D-calcium</th> <th>Protein&</th> <th>Amino</th> <th>Polyethylene</th>	SN	Company	US Pat No	Year		Example	Etocrylene	Dex-	D-calcium	Protein&	Amino	Polyethylene
Kirker 7640314B2 2004 1 1 -								Panthenol	panthothenate	Lanolin	methoxysilane	Terephathalate
Tevco 6537530B2 2003 2 4 -	-	Kirker	7640314B2		1	1	I	1	I	. 1	I	1
Loreal 6555096B2 2003 1 4 -	2	Tevco	6537530B2		2	4	ı	ı	,	1	ı	1
Loreal 6555096B2 2003 1 1 -	m	Loreal	6555096B2		1	4	1	1		1	1	1
Engelhard 66269891 2003 1 1 -	4	Loreal	6555096B2		2	4	I	1		1	1	3
Shiseido 6656486B2 2003 1 25 -	S	Engelhard	6626989B1	2003	1	1	-	1		1	1	1
ProStrong 6627181B1 2003 1 3 -	9	Shiseido	6656486B2	2003		25	1	•	-	1	1	1
Loreal 6555096B2 2003 3 4 -	7	ProStrong	6627181B1	2003	1	3	1	1		1	1	1
Loreal 6555096B2 2003 4 4 -	8	Loreal	6555096B2	2003	3	4	-	1		1	1	1
Kirker6352687B1200213 <td>6</td> <td>Loreal</td> <td>6555096B2</td> <td>2003</td> <td>4</td> <td>4</td> <td></td> <td>TAN</td> <td></td> <td>1</td> <td></td> <td></td>	6	Loreal	6555096B2	2003	4	4		TAN		1		
Revlorn 6485731B1 2002 3 6 -	10	Kirker	6352687B1	2002	1	3	-		-	1		1
Loreal 6156325 2000 1 3 0.5 -	11	Revlon	6485731B1	2002	3	9		-		1		
Loreal 6156325 2000 2 3 0.5 -	12	Loreal	6156325	2000	1	3	0.5			-		1
Loreal 6156325 2000 3 3 0.5 -	13	Loreal	6156325	2000	2	3	0.5	-		1		1
Maybeline 5972095 1999 1 1 -	14	-	6156325	2000	3	3	0.5	1	-	-		
Kirker59772171999440.05Kirker5863523199915	15			1999	1	1	1	1	-	1		1
Kirker 5863523 1999 1 5 -	16	-	5977217	1999	4	4	0.05	1				
Maybeline 5766332 1998 1 1 -	17		5863523	1999	- 1	5	-	1		1		
Almell 5662891 1997 1 4 - 0.006 0.059 1.17	18	-		1998	1	1	1	1	1	1	ı	I
2.5	19	Almell	5662891	1997	1	4	I	0.006	0.006	0.059	1.17	
					ลัย							

	Dioctyl	Adipate		4.605		1	•		•	•								•	1		
	Diethylene glycol	diethyl ether	1	I	1		1	20	1	1	1	ı	1	1	1	1	1	1	1	1	1
	Sucrose	ester resin		2.831		T		8	1		1		1		1	1	1	1			
Others (continue)	Mono- butoxy	diethylene glycol	1	1			3		-	-	1	-	-	-	•			1	1	1	I
Oth	Amyl	acetate	5	-	•	-	44.8		•	•				-	1	1	1	1	1	1	1
	2,2,4trimethyl- 1.3-	pentanediol diisobutyrate			-			-	-				-	-	-		1		1		1
	Phosphoric	acid	0.03	90	-	1	-	-	-		1		-			-	0	1	1	1	•
	Example		1	4	4	4	1	25	3	4	4	3	9	3	3	3	1	4	5	1	4
	Compos	1	1	2	6 1 D	2	11	1	1	ю	4	1	Э	010	2	Э	1	4	1	1	1
ttion	Year		2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
Information	US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
	Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	SN		1	2	ŝ	4	2	9	7	8	6	10	11	12	13	14	15	16	17	18	19

		yl																				Τ	
Others (continue)		Trifluoromethyl	C1-4 alkyl	dimethicone		1	1	1		1	1	1	1	1	0.02	1	1	1	1	1	1	1	1
	Tetrabutyl	phenyl	hydroxybenzoat	e	1	,	1	1	1	1	1	1		1	0.25	1		1	1	1	1	1	1
		Triacetin			1	1							1		6.0	1				1	•		1
		Water			ı	1	1	1	1					1	0.5							1	1
	Triben	zoin			1	1	1	1	1	1	•	1	1	1	10.33	I	I	I	1		1		8
		Butylphthalimide	Isopropyl	phthalimide		3.733					-												1
	Exam	ple			1	4	4	4	1	25	3	4	4	3	9	3	e	e	1	4	5	1	4
	Com	sod			1	2	1	2	1	1	1	3	4	1	3	1	2	e	1	4	1	1	e 1
Information		Year	٩		2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
		US Pat No			7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
		Company			Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	S	Z			1	7	3	4	S	9	2	8	6	10	11	12	13	14	15	16	17	18	19

	-																				
Others (continue)	Aloe barbadensis	extract			•	1	•	1	1	1	•	1	0.001	-	1		1		1	1	1
	Tocopherol	acetate	1	1	•	•	-	-	-	1			0.001		-				1		1
	Retinyl	palmitate	•	1		1	1		1	1	-	1	0.001	1	I	I	1	1	1		1
	Dioctyldodecyl	iluoroneptyl			•			•	18-01	•	-		0.001					-			1
Information	Example		1	4	4	4	1	25	3	4	4	3	9	3	3	3	1	4	5	1	4
	Compos		1	2	1	2	1	1	1	3	4	1	3	1	2	3	1	4		1	1
	Year		2004	2003	2003	2003	2003	2003	2003	2003	2003	2002	2002	2000	2000	2000	1999	1999	1999	1998	1997
	US Pat No		7640314B2	6537530B2	6555096B2	6555096B2	6626989B1	6656486B2	6627181B1	6555096B2	6555096B2	6352687B1	6485731B1	6156325	6156325	6156325	5972095	5977217	5863523	5766332	5662891
	Company		Kirker	Tevco	Loreal	Loreal	Engelhard	Shiseido	ProStrong	Loreal	Loreal	Kirker	Revlon	Loreal	Loreal	Loreal	Maybeline	Kirker	Kirker	Maybeline	Almell
	SN		1	7	ŝ	4	5	9	7	8	6	10	11	12	13	14	15	16	17	18	19